

AMENDMENTS TO THE SPECIFICATION

In the Specification

Please insert as the first paragraph of the specification:

3/5/05
HN

-- The present application is a divisional of U.S. Patent Application Serial
Number 09/752,938, filed Dec. 29, 2000, ^{now US Pat. 6,710,845} entitled "PURGING GAS FROM A
PHOTOLITHOGRAPHY ENCLOSURE BETWEEN A MASK PROTECTIVE DEVICE
AND A PATTERN MASK". --